

(19)



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(11)

EP 0 760 544 B1

(12)

EUROPEAN PATENT SPECIFICATION

(45) Date of publication and mention
of the grant of the patent:
18.10.2000 Bulletin 2000/42

(51) Int Cl.7: **H01S 5/02, H01S 5/10,**
H01S 5/40, G02F 1/015

(21) Application number: **96110303.3**

(22) Date of filing: **26.06.1996**

(54) Integrated device with monolithically formed light emitting element and external modulator/light receiving element

Monolithisch-integrierte Anordnung von lichtemittierendem Element und externem Modulator/lichtempfindlichem Element

Dispositif intégré comportant un élément monolithique émetteur de lumière et modulateur externe/récepteur de lumière

(84) Designated Contracting States:
CH DE FR GB IT LI

(30) Priority: **28.08.1995 JP 21901095**

(43) Date of publication of application:
05.03.1997 Bulletin 1997/10

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- **PATENT ABSTRACTS OF JAPAN** vol. 18, no. 230 (E-1542) [6570], 26 April 1994 & JP-A-06 021581 (FUJITSU LTD), 28 January 1994,
- **APPLIED PHYSICS LETTERS**, vol. 55, no. 26, 25 December 1989, NEW YORK US, pages 2724-2726, XP000127413 A. SCHERER ET AL.: "FABRICATION OF MICROLASERS AND MICRORESONATOR OPTICAL SWITCHES"

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Description

[0001] The present invention relates to an integrated device in which a light emitting element and an external modulator (or an element functioning as light receiving element) are monolithically formed, and an integrated device in which a light emitting element and a light receiving element are monolithically formed.

[0002] Patent Abstracts of Japan, Vol. 18, No. 230 (E-1542) (6570), April 26, 1994; & JP-A-06021581 (28 Jan. 1994) describes a semiconductor surface type optical switch comprising a semiconductor substrate which has arranged on two opposite sides a first and second resonator. The resonator is constituted as a surface emitting laser and the other resonator is constituted as an optical modulator. Both resonators have semiconductor distributed reflecting (DBR) mirrors and are vertical to the substrate.

[0003] By virtue of development of optical fibers, optical communication technology has widely been applied to technical fields of high-speed, long-distance and large-capacity telecom systems, middle-distance telecom systems and short-distance data communication systems. Light emitting elements, light receiving elements and modulators for data transmission are key components for optical communication technology in these fields.

[0004] In the prior art, however, a light emitting element, a light receiving element and a modulator are generally manufactured independently as discrete semiconductor elements. Accordingly, the cost for manufacturing one optical system becomes enormous since time and labor is needed for the assembly and wiring of each semiconductor element.

[0005] For example, consideration will now be given of the case of using a semiconductor laser (e.g. laser diode) including a modulation function as a light emitting element.

[0006] When such a direct-modulation type semiconductor laser element is used, a transmitter unit needs to comprise an optical connector for coupling a laser beam output from the semiconductor laser to an optical fiber, a monitoring light receiving element (e.g. PIN photodiode) for stabilizing laser intensity, and an arrangement for coupling a laser beam from the opposite side of the semiconductor laser to the monitoring light receiving element.

[0007] A receiver unit is also needed in addition to the transmitter unit. In the prior art, however, the transmitter unit and receiver unit cannot share a single optical fiber, for the following reasons.

a) The receiver unit generally includes a PIN photodiode (light receiving element). Since the PIN photodiode is formed on the major surface of a semiconductor substrate, a light signal must be made incident on the major surface of the semiconductor substrate perpendicularly. By contrast, in the case

of a laser diode (light emitting element), a light signal is generally emitted from a surface perpendicular to the major surface of a semiconductor substrate, i.e. a cleaved surface formed by cleaving the semiconductor substrate.

b) The PIN photodiode is a device rendered operative by application of an electric field, whereas the laser diode is a device rendered operative by injection of current. It is difficult, therefore, to use a common drive circuit both for driving the PIN photodiode and for modulating the laser diode.

[0008] Recently, a surface emitting type laser has been proposed, wherein a cavity is formed perpendicular to the surface of a semiconductor substrate and a laser beam is emitted from the surface of the semiconductor substrate. In the surface emitting laser, however, an electric current is injected at high density in an active layer of a small volume and the laser tends to generate heat, resulting in low output power. Thus, this laser has not yet been put to practical use.

[0009] On the other hand, a DFB (Distribution Feedback) laser is used as a light emitting element in a transmitter for high-speed, long-distance systems. The DFB laser oscillates in a single longitudinal mode, unlike an FP (Fabry-Perot) laser oscillating in a multi-longitudinal mode.

[0010] The DFB laser has a grating formed along the cavity direction. The grating has a predetermined period which determines the wavelength of the single longitudinal mode.

[0011] A DBR (Distributed Bragg Reflector) laser, like the DFB laser, is a device making use of a grating. The principle of oscillation in the single longitudinal mode of the DBR laser is similar to that of oscillation in the single longitudinal mode of the DFB laser.

[0012] Thus, in the DBR laser, too, the waveform of a signal, which has passed through an optical fiber with a wavelength distribution, does not change, and the signal can be transmitted over a long distance.

[0013] However, the modulation bandwidth of an optical output from the directly modulated DFB laser is limited by an interaction between carriers produced by current and photons generated by carriers and is close to the bandwidth limit. In addition, even if the DFB laser is operated at a narrow single spectral line, complex dynamic characteristics and instability may lead to a problem of broadening the oscillation linewidth (wavelength chirp).

[0014] Accordingly, the direct-modulation type DFB laser is not suitable for much longer distance signal transmission.

[0015] In order to overcome the above problems, attention has been paid to systems using an external modulator. In this method, a laser diode is driven by a DC current. The modulation is not performed in the laser diode, and output light of the laser diode is modulated by the external modulator.

[0016] The external modulator may be of Mach-Zender type, EA type (Electro-Absorption type), etc. Recently, EA type external modulators are predominant, which permit monolithic integration of laser diodes with the external modulators.

[0017] Some specific conventional devices will now be described with reference to prior-art documents.

[0018] FIG. 1 shows a device disclosed in Document 1 (K. Wakita, et al., IEEE Photonics Technology Letter, vol. 5, No. 8, p. 899, 1993).

[0019] In this device, a DFB laser and an EA modulator are integrated monolithically. The DFB laser and EA modulator are connected coaxially and a laser beam from the DFB laser is emitted in parallel to the surface of the substrate via the modulator.

[0020] FIG. 2 shows a device disclosed in Document 2 (I. Kotani, et al., IEEE Photonics Technology Letter, vol. 5, No. 1, p. 62, 1993).

[0021] In this device, too, a DFB laser and an EA modulator are integrated monolithically. Like the device shown in FIG. 1, the DFB laser and EA modulator are connected coaxially and a laser beam from the DFB laser is emitted in parallel to the surface of the semiconductor substrate via the modulator.

[0022] FIGS. 3A to 3E show a device disclosed in Document 3 (M. Aoki, et al., Electronics Letters, vol. 27, No. 23, p. 621, 2138, 1991).

[0023] In this device, too, a DFB laser and an EA modulator are integrated monolithically. Like the device shown in FIG. 1, the DFB laser and EA modulator are connected coaxially and a laser beam from the DFB laser is emitted in parallel to the surface of the semiconductor substrate via the modulator.

[0024] FIG. 4 shows a device disclosed in Document 4 (U. Koren, et al., Electronics Letters, vol. 23, No. 12, p. 621, 1987).

[0025] This device is a discrete semiconductor device in which an EA modulator is formed monolithically.

[0026] The devices of Documents 1 to 3 are characterized in that the DFB laser and EA modulator are integrated coaxially in the direction of the waveguide.

[0027] The DFB laser having an active layer of an MQW (Multi-Quantum Well) structure has a driving electrode, to which a DC current is supplied to emit an output beam. The output beam is guided as a waveguide-mode beam to a waveguide in a modulation region. In the modulation region, only a layer necessary for guiding waves is formed, and an active layer and a grating are not provided.

[0028] If a reverse bias voltage is applied to the modulation region, a field effect, e.g. Stark effect or Franz-Keldysh effect, occurs, and an absorption band of the waveguide is shifted to the longer wavelength side. As a result, the output light of the modulator is greatly attenuated, which implies the modulation by applying voltage. In addition, a very high speed operation higher than 10 Gbps is theoretically enabled, with extremely small chirp.

[0029] However, in order to achieve the above ideal condition, electrical isolation must be maintained between the laser diode and external modulator. Furthermore, the optical return from the first and/or the modulator to the laser must be minimized to avoid the occurrence of chirp and instability of the laser.

[0030] The electrical isolation can be effected by increasing a physical distance between the laser diode and the external modulator. If the physical distance between the laser diode and external modulator is increased, the area of the chip would increase, and the optical coupling between the two devices becomes small.

[0031] To minimize the optical return to the laser is very difficult. In general, in DFB lasers and DBR lasers, the phase of light traveling reciprocally within the resonator varies due to residual reflection. Consequently, the oscillation wavelength of the laser and the intensity of output would fluctuate and in a worst case, the oscillation becomes unstable.

[0032] In conventional devices, in general, a laser beam is emitted from the laser diode in parallel to the surface of the semiconductor substrate. Specifically, when a laser diode and an external modulator are monolithically integrated, the laser diode and external modulator are connected coaxially.

[0033] This being the case, it is difficult to use planar techniques in the process of manufacturing such devices, and the manufacture thereof is difficult.

[0034] The present invention has been made to overcome the above-mentioned drawbacks occurring when a light emitting element and an external modulator are monolithically integrated. An object of the invention is to provide an integrated device which is of a surface light emission type, requires no cleaving, permits use of an external modulator as a light receiving element, permits easy integration of the light emitting element and external modulator, achieves stable operation, and remarkably reduces chirp. This object is solved by an integrated device according to claim 1. Further advantageous embodiments and improvements of the invention can be taken from the dependent claims.

[0035] An advantage of the invention is the possibility to apply an integrated device of the light emitting element and external modulator or an integrated device of the light emitting element and the light receiving element as a high-speed array device for data communication.

[0036] According to an aspect of the invention there is provided an integrated device comprising:

50 a semiconductor substrate;
a light emitting element of a surface emission type, provided on a first major surface of the semiconductor substrate, the light emitting element radiating light towards the semiconductor substrate; and
55 an external modulator formed on a second major surface of the semiconductor substrate and situated in a region opposed to the light emitting element.

[0037] The light emitting element may be one of a DFB laser and a DBR laser, each of which has a grating along a waveguide. The grating may have phase shift regions and the shift amount in the phase shift regions may be 3/8 of the wavelength of the light.

[0038] The light emitting element may have a waveguide and both end portions of the waveguide may be provided with reflection-free structures such as anti-reflection coatings. The external modulator may comprise an element having absorption properties variable due to application of an electric field.

[0039] The external modulator may function also as a light receiving element for monitoring an optical signal output from the light emitting element. The external modulator may function also as a light receiving element for receiving and detecting an optical signal input from the outside.

[0040] The integrated device according to this invention may further comprise a layer, formed on the second major surface of the semiconductor substrate, for shutting out light output from the light emitting element to a region other than a region where the external modulator is situated. The output from a region faced on the external modulator is situated may be highest.

[0041] The integrated device according to this invention may further comprise a lens for decreasing a divergence of the light output from the light emitting element, the lens being situated between the light emitting element and the external modulator.

[0042] The second major surface of the semiconductor substrate may be inclined to the first major surface of the semiconductor substrate by a predetermined angle. The semiconductor substrate may be semi-insulating, and the light emitting element and the external modulator may be electrically isolated from each other.

[0043] The semiconductor substrate may pass the light output from the light emitting element and guide the light to the external modulator. The semiconductor substrate may be InP.

[0044] The light emitting element may radiate light in directions toward and away from the semiconductor substrate, and the light radiated in the direction away from the semiconductor substrate may be reflected by a reflection mirror and reflected towards the semiconductor substrate.

[0045] The light emitting element may include an active layer having one of an MQW (Multi-Quantum Well) structure and a strained MQW structure.

[0046] The external modulator may have an MQW (Multi-Quantum Well) structure.

[0047] The integrated device according to this invention may further comprise a printed circuit board coupled to the light emitting element and bonding wires for connecting the external modulator and wiring on the printed circuit board.

[0048] According to another aspect of the invention there is provided an integrated device comprising:

5 a semiconductor substrate;
a plurality of surface emission type light emitting elements, provided on a first major surface of the semiconductor substrate, the light emitting elements radiating light towards the semiconductor substrate; and

10 a plurality of external modulators formed on a second major surface of the semiconductor substrate and situated in regions opposed to the light emitting elements.

[0049] Each of the light emitting elements may be one of a DFB laser and a DBR laser each having a grating along a waveguide. The grating may have phase shift regions and the shift amount in the phase shift regions may be 3/8 of the wavelength of the light.

[0050] The light emitting element may have a waveguide, and both end portions of the waveguide may be provided with reflection-free structures such as anti-reflection coatings. Each of the external modulators may comprise an element having absorption properties variable due to application of an electric field.

[0051] One of the external modulators may function also as a light receiving element for monitoring an optical signal output from the light emitting element. Each of the external modulators may function also as a light receiving element for receiving and detecting an optical signal input from the outside.

[0052] The integrated device according to this invention 30 may further comprise a layer, formed on the second major surface of the semiconductor substrate, for shutting out light output from the light emitting elements to a region other than region where the external modulators are situated.

[0053] The second major surface of the semiconductor substrate may be inclined to the first major surface of the semiconductor substrate by a predetermined angle. The semiconductor substrate may be semi-insulating, and the light emitting elements and the external modulators may be electrically isolated from each other.

[0054] The semiconductor substrate may pass the light output from the light emitting elements and guide the light to the external modulators. The semiconductor substrate may be InP.

[0055] Each of the light emitting elements may include an active layer having one of an MQW (Multi-Quantum Well) structure and a strained MQW structure. The external modulator may have an MQW (Multi-Quantum Well) structure.

[0056] According to yet another aspect of the invention there is also provided an integrated device comprising:

55 a light emitting element having a radiation mode in which light is emitted from all over the grating;
an external modulator situated on a light emission side of the light emitting element at a region where the light has a highest intensity; and

a layer, provided between the light emitting element and the external modulator, for electrically isolating the light emitting element and the external modulator and passing the light output from the light emitting element.

[0057] Another aspect of the invention provides an integrated device comprising:

a light emitting element including a waveguide and having a guided mode in which light is emitted from end portions of the waveguide path;
an external modulator for controlling cut/transmission (ON/OFF) of the light;
a reflection mirror for guiding the light from the light emitting element to the external modulator and a layer, provided between the light emitting element and the external modulator, for electrically isolating the light emitting element and the external modulator and passing the light output from the light emitting element.

[0058] Another aspect of the invention is an integrated device comprising:

a semiconductor substrate;
a light emitting element of a surface emission type, provided on a first major surface of the semiconductor substrate, the light emitting element radiating light in directions towards and away from the semiconductor substrate; and
a reflection mirror, provided on a second major surface of the semiconductor substrate, for reflecting the light radiated towards the semiconductor substrate.

[0059] According to another aspect there is also provided an integrated device comprising:

a semiconductor substrate;
a light emitting element of a surface emission type, provided on a first major surface of the semiconductor substrate, the light emitting element radiating light in directions towards and away from the semiconductor substrate; and
a light receiving element provided on a second major surface of the semiconductor substrate and situated in a region faced to the light emitting element.

[0060] The light emitting element may be one of a DFB laser and a DBR laser, each of which has a grating along a waveguide. The grating may have a phase shift region and the shift amount in the phase shift region is 3/8 of the wavelength of the guided wave.

[0061] The light receiving element may be a PIN photodiode. The light receiving element may have an active layer, an opening portion being formed in a part of the active layer, the light emitting element being formed in

a position corresponding to the opening portion. The intensity of light may be highest in a region where the light receiving element is situated.

[0062] The semiconductor substrate may contain impurities, and the light emitting element and the light receiving element may be electrically connected to each other.

[0063] The semiconductor substrate may pass the light output from the light emitting element and couple the light to the light receiving element. The semiconductor substrate may be InP. The light emitting element may include an active layer having one of an MQW (Multi-Quantum Well) structure and a strained MQW structure.

[0064] This invention can be more fully understood from the following detailed description when taken in conjunction with the accompanying drawings, in which:

FIG. 1 shows a conventional integrated device;
FIG. 2 shows a conventional integrated device;
FIGS. 3A to 3E show a conventional integrated device;
FIG. 4 shows a conventional EA modulator;
FIGS. 5A and 5B show a conventional GCL (Grating-Coupled Laser);
FIG. 5C shows a light intensity distribution profile;
FIG. 6 shows an integrated device according to a first embodiment of the present invention;
FIG. 7 is a cross-sectional view taken along line VII-VII in FIG. 6;
FIG. 8 shows the integrated device of FIG. 6 which is mounted on a board;
FIG. 9 shows an integrated device according to a second embodiment of the present invention;
FIG. 10 shows an integrated device according to a third embodiment of the present invention;
FIG. 11 shows an integrated device according to a fourth embodiment of the present invention;
FIG. 12 shows an integrated device according to a fifth embodiment of the present invention;
FIG. 13 shows an example of an integrated device not belonging to the embodiments of the present invention; FIG. 14 shows an integrated device according to a sixth embodiment of the present invention;
FIG. 15 shows an integrated device according to a seventh embodiment of the present invention;
FIG. 16 shows an integrated device according to an eighth embodiment of the present invention; and
FIG. 17 shows a GCL.

[0065] Integrated devices according to preferred embodiments of the present invention will now be described with reference to the accompanying drawings.

[0066] In the present invention, a light emitting element comprises a surface emitting type element of which output beam is emitted in a direction perpendicular to the surface of a semiconductor substrate. In the present invention, it is supposed that the light emitting

device is mainly used as a backlight, as in a TFT-LCD (Thin Film Transistor-Liquid Crystal Display). In addition, the present invention is directed to DFB lasers and DBR lasers of a grating-coupled (GC) type.

[0067] The grating-coupled laser (GCL) has an output beam not in a guided mode but in a radiation mode. Thus, the beam divergence along the cavity direction is as small as several degrees. If the angle of a reflected beam is slightly displaced, the reflected beam does not return and couple back to the waveguide structure.

[0068] In the case of short-distance communication, a surface emitting type LED can be used as a backlight. However, since the output light of the surface emitting type LED has a large spectral band width, the dynamic range of wavelength of a modulator needs to be increased, which is not so practical actually.

[0069] The EA modulator is not of a waveguide type but of a surface type, and it is a field effect type device driven by a reverse bias. A PIN photodiode as light receiving element also utilizes an electric field effect. For this reason, the surface-type EA modulator can be operated as PIN photodiode. In this case, a modulator as a transmitter and PIN photodiode as a receiver can be formed of devices of the same structure.

[0070] As a result, bidirectional communication can be performed with use of only one optical fiber without any distribution branches into both transmitter and receiver. It is also possible to constitute drive circuits of the transmitter and the receiver as a common voltage supply. Since the surface-type device can be easily integrated, planar techniques are applicable.

[0071] Complete electrical and optical isolation can be obtained if the light emitting element and EA modulator, or the light emitting element and light receiving element, are monolithically formed, with one of the paired elements provided on one surface of a semi-insulating substrate and the other element provided on the other surface of the semi-insulating substrate. In addition, in this case, the manufacturing process is facilitated by making use of planar techniques.

[0072] Furthermore, light input and output surfaces can be processed to have lens-shapes, and therefore the performance can be enhanced.

[0073] As has been described above, the present invention is not a simple combination of prior-art techniques but can bring about a remarkable effect.

[0074] The GCL (Grating-Coupled Laser) will now be described.

[0075] FIG. 17 shows a GCL. The GCL, i.e. a surface emitting type DFB laser using a grating of a second-order or a higher order, has a guided mode in which a laser beam is emitted from end faces parallel to the major surface of a semiconductor substrate, and a radiation mode in which a laser beam is emitted from the grating. Specifically, if the grating is of the second-order, light is emitted in a direction perpendicular to the length direction of the cavity.

[0076] The radiation mode is emitted vertically to the

grating, i.e. the upward and downward directions. Accordingly, one of the vertically emitted beams can be used as an optical output signal. The other beam may be absorbed for nonuse, or reflected for coherence to intensify the output signal, or used for monitoring the output signal.

[0077] The light beam in the radiation mode is emitted from the waveguide. Accordingly, the output signal may be intensified or weakened by making use of optical coherence in the radiation mode. In addition, the optical output may be provided with a distribution in the direction of the cavity and the external modulator may be situated at a position where the optical output is maximum.

[0078] One means for achieving the above-described principle is a structure ($3\lambda/8$ phase shift) wherein the phase of light is shifted by $3/8$ of guided wavelength at two locations near the center of the GCL. Specifically, constructive interference of light in the radiation mode occurs at these two locations.

[0079] This structure is described in Document 5 (Japanese Patent Application No. 63-317818 corresponding to USP 4,958,357, European Patent Application No. 88312036.2, Korean Patent No. 058391, and J. Kinoshita, p. 407, IEEE Journal of Quantum Electronics, vol. QE-26, No. 3, 1990).

[0080] FIGS. 5A and 5B shows a device disclosed in Document 5. FIG. 5A is a cross-sectional view, taken in a longitudinal direction of a resonator, showing an InGaAsP/InP type DFB laser with $3\lambda/8$ phase shift. FIG. 5B shows the InGaAsP/InP type DFB laser with $3\lambda/8$ phase shift, as viewed from the end face side of the resonator. FIG. 5C shows a light intensity distribution profile along the cavity.

[0081] An InGaAsP active layer 2 and an InGaAsP waveguide layer 3 having a wider band gap than the InGaAsP layer 2 are formed on an n-type InP layer 1. A second-order grating 15 is formed on the InGaAsP waveguide layer 3. The grating 15 is provided with two $3\lambda/8$ phase-shift portions 16 and 16' between which a central portion of the resonator is located.

[0082] A p-InP layer 4 and a p-InGaAsP ohmic-contact layer 5 are formed on the grating 15. The p-InP layer 4 and contact layer 5 are mesa-etched in stripes so as to have a ridge-type waveguide structure. An electrode 20 is put in contact with the p-InGaAsP ohmic-contact layer 5, and an electrode 21 is put in contact with the n-type InP layer 1. An output window 30 is formed in the electrode 20 in a position corresponding a region between the $3\lambda/8$ phase-shift portions 16 and 16'.

[0083] Components of two traveling waves R and S, which reciprocally propagate in the waveguide, are radiated by the second-order grating 10 in a direction vertical to the substrate as a beam 100 with very narrow beam divergence peculiar to the radiation mode, i.e., as narrow as a few degree.

[0084] The light components radiated downward are not considered, supposing that they are scattered on the bottom surface of the substrate. In this case, as shown

in FIG. 5C, two radiation-mode beams are intensified between the $3\lambda/8$ phase-shift portions 16 and 16' (as indicated by a solid line). However, if the $\lambda/8$ phase-shift portion is used, the optical output is greatly reduced. The beam divergence of radiation mode 110 in the direction perpendicular to the waveguide is about 30° of full width at half maximum.

[0085] The senior patent application (Document 5) by the inventor proposes modulation of output by varying a phase shift amount. In this case, however, the wavelength varies if the shift amount varies. Thus, this technique is disadvantageous in decreasing chirp. In addition, since modulation is effected by electric current, the modulating unit and light emitting unit are not completely separated and a mutual effect or crosstalk may occur between the modulating unit and light emitting unit.

[0086] In the following embodiments, the optical output is modulated not by varying the phase-shift amount, but by means of an external modulator.

[0087] FIGS. 6 and 7 show a first embodiment of the integrated device comprising a light emitting element and an external modulator according to the present invention. FIG. 7 is a cross-sectional view taken along line VII-VII in FIG. 6.

[0088] An n-InP layer 1, an InGaAsP active layer 2 and an InGaAsP waveguide layer 3 are formed on a first major surface of a semi-insulating InP substrate 1". The InGaAsP waveguide layer 3 has a wider band gap than the InGaAsP active layer 2.

[0089] A second-order grating 10 is formed on the InGaAsP waveguide layer 3. The grating 10 is provided with two ($3\lambda/8$) phase-shift portions 16 and 16' between which a central portion of a resonator is located. The light intensity is highest in a region between the phase-shift portions 16 and 16'.

[0090] The active layer 2 may have an MQW (Multi-Quantum Well) layer structure, with which high performance is achieved by quantum effect, or a strained MQW layer structures. In the following description, active layers include those with such structures.

[0091] A p-InP layer 4 and a striped p-InGaAsP ohmic-contact layer 5 are formed on the grating 10. The ohmic-contact layer 5 and p-InP layer 4 are mesa-etched to constitute a GCL 50 of a ridge type waveguide structure.

[0092] In the GCL, one of radiation-mode beams emitted vertically upward and downward, which is radiated to the ridge 31 side, is not considered since it is absorbed by the ohmic layer 5 or scattered by the ridge structure.

[0093] Both end portions of the resonator of the GCL 50 are provided with anti-reflection (AR) coatings. Unless end-facet reflection of guided-mode light is prevented, a single longitudinal mode is not easily obtained or the phase-shift portions 16 and 16' are not effective.

[0094] Radiation from both end facets of the resonator of the GCL 50 is not necessary and is detrimental. In order to prevent radiation from both end facets, it is nec-

essary to weaken the light intensity at both end facets.

[0095] The light intensity at both end facets can be weakened by dispensing with a diffraction grating near both end faces, creating an unpumped region near both end faces, or removing an active layer and creating a window structure comprising only the InP layer 12.

[0096] Electrodes will now be described.

[0097] An n-side electrode 21 is formed on the n-InP layer 1. The n-side electrode 21 is electrically isolated from a p-side electrode 20. The electrodes 20 and 21 are formed simultaneously with electrodes 20' and 21' of a modulator (described below) which is formed on a second major surface of the substrate 1" and serves also as a photodiode. The ridge stripes may be formed after the crystal growth on the second major surface of the substrate 1".

[0098] The second major surface of the semi-insulating substrate 1" is inclined by a few degrees (e.g. 3°) with respect to the first major surface of the semi-insulating substrate 1".

[0099] An InGaAs absorption layer 6 is formed on the second major surface of the semi-insulating substrate 1". An opening (window) is formed in the absorption layer 6 in a position corresponding to a region between the

[0100] two ($3\lambda/8$) phase-shift portions 16 and 16' where the radiation-mode beam has a highest intensity. A radiation-mode beam 100 from the GCL 50 is made incident on an EA modulator 60 via the opening. The opening functions to prevent an excess radiation-mode beam from leaking out of the region other than the modulator.

[0101] A p-InP layer 7, an MQW structure 8 of a 100-layer, an n-InP layer 9 and an n⁺-InP layer 10 are formed on the semi-insulating substrate 1". These layers 7 to 10 are formed in a cylindrical mesa shape. An SI (Semi-Insulating)-InP layer 11 is provided around the layers 7 to 10.

[0102] Since the beam is output in a direction perpendicular to the surface of the wafer, it is possible to form a lens on the surface of the wafer by planar techniques. In other words, in the integrated device of the present invention, the integrated device can be easily combined with an optical fiber. Bonding wires 32 are connected to bonding pads provided on the electrodes 20' and 21'.

[0103] FIG. 8 schematically shows the integrated device shown in FIGS. 6 and 7, which is mounted on a printed circuit. In the present invention, the integrated device is flip-chip-mounted such that the GCL 50 which produces heat due to electric current is situated downward.

[0104] Specifically, the electrodes 20 and 21 of the integrated device are connected to wiring 18 on the print-

ed circuit 17 by means of bumps 19. On the other hand, the electrodes 20' and 21" are connected to the wiring 18 by means of bonding wires 32.

[0105] In the above-described integrated device, if a reverse bias is applied to the EA modulator 60 in the transmission mode, the radiation-mode beam 100 is absorbed by the MQW layer 8 and is not emitted from the integrated device.

[0106] Radiation-mode beams 101 propagating through regions outside the phase-shift portions 16 and 16' of the GCL 50 are absorbed by a photodiode 61 and monitored. The photodiode 61 has the same structure as the EA modulator 60. If a predetermined reverse bias is applied to the EA modulator, the EA modulator functions as photodiode. By monitoring the radiation-mode beam 100, the intensity of the output beam 100 from the GCL 50 is controlled to be constant.

[0107] On the other hand, in the receiver mode, the GCL 50 is turned off and a predetermined reverse bias is applied to the EA modulator 60. As a result, the EA modulator 60 functions as photodiode and can detect an optical signal. In the present invention, the transmission unit and the reception unit can be formed of the integrated device of the same structure.

[0108] FIG. 9 shows an integrated device of a light emitting element and an external modulator according to a second embodiment of the invention.

[0109] The integrated device of the second embodiment differs from that shown in FIGS. 6 and 7 in the following respects.

[0110] The radiation-mode beam from the GCL 50 has a uniform output distribution along the resonator direction. Linearly arranged EA modulators 60 are formed on the GCL 50. Each modulator 60 has a cylindrical mesa structure. One of the EA modulators 60 can be used as a monitoring photodiode.

[0111] In this embodiment, the radiation-mode beam of the GCL 50 has a uniform distribution in the longitudinal direction of the resonator. However, the output distribution of the radiation-mode beam in the longitudinal direction of the resonator may be varied by forming a phase-shift portion at a proper location of the grating.

[0112] FIG. 10 shows an integrated device of a light emitting element and an external modulator according to a third embodiment of the invention.

[0113] The integrated device of the second embodiment differs from that shown in FIGS. 6 and 7 in the following respects.

[0114] A plurality of GCLs 50 are formed on a first major surface of the semi-insulating substrate 1". The radiation-mode beam from each GCL 50 has a uniform output distribution along the resonator direction. Linearly arranged EA modulators 60 are formed on each GCL 50. Each modulator 60 has a cylindrical mesa structure. One of the EA modulators 60 can be used as a monitoring photodiode.

[0115] If the periods of diffraction gratings of the GCLs 50 are made to differ from one another, the radiation-

mode beams output from the GCLs 50 have different oscillation wavelengths. Thus, the integrated device according to this embodiment can be used as a light source for multi-wavelength communication.

[0116] In the semiconductor devices shown in FIGS. 6 to 10, the first and second major surfaces of the semi-insulating substrate 1" are inclined to each other by several degrees (e.g. 3°) in the direction of the resonator of the GCL 50. By virtue of the inclination, a reflection beam does not return to the resonator of the GCL 50 since the beam divergence of the radiation-mode beam is a few degrees in the resonator (cavity) direction.

[0117] Since the reflection beam from the modulator or optical fiber does not return to the GCL 50, the operation of the integrated device is stabilized and chirp is reduced.

[0118] FIG. 11 shows an integrated device of a light emitting element and an external modulator according to a fourth embodiment of the invention.

[0119] As has been described above, the beam divergence of the radiation-mode beam from the GCL 50 is a few degrees and very small in the longitudinal direction of the resonator. In the width direction of the waveguide, however, the beam divergence of radiation of the radiation-mode beam 110 is about 30° in terms of full width at half maximum. It is necessary, therefore, to efficiently converge the radiation-mode beam 110 on the modulator 60.

[0120] In this embodiment, for this purpose, a lens 55 is formed on the GCL (50)-side major surface of the substrate 1".

[0121] Specifically, a curved groove is formed in the GCL (50)-side major surface of the substrate 1. An InGaAsP layer is formed on the major surface of the substrate 1" so as to fill the groove. The InGaAsP layer has a greater refractive index than the substrate 1" and is transparent. Thus, the lens 55 is formed in the groove.

[0122] FIG. 12 shows an integrated device of a light emitting element and an external modulator according to a fifth embodiment of the invention.

[0123] This embodiment does not adopt the means for causing optical interference by phase shift, thereby intensifying a radiation mode beam. Instead, a light beam radiated from a GCL 50 towards a substrate 1" is made to interfere with a light beam radiated from the GCL 50 towards a ridge (i.e. in a direction opposite to the substrate 1"), thereby intensifying the radiation mode beam.

[0124] Specifically, in the present embodiment, a reflection mirror 56 comprising a high-reflection multi-layer film is provided on the ridge side (p-side). A light component 103 propagating on the ridge side is reflected by the reflection mirror 56 and turned towards the substrate 1". Thus, the light component 102 output towards the substrate 1" and light component 103 reflected by the reflection mirror 56 interfere with each other.

[0125] In this case, the shape of the grating (diffraction grating) 15 and the position of the reflection mirror

56 are controlled so that the light components 102 and 103 interfere with and intensify constructively each other. As a result, the modulator 60 receives a radiation mode beam having a great light intensity and the intensity of the output beam from the integrated device increases.

[0126] FIG. 13 shows an example of an integrated device of a light emitting element and an external modulator not belonging to the invention.

[0127] In this embodiment, the light emitting element is composed of not a GCL but an oblique reflection type DFB laser 51. A diffraction grating 15' is of the first order. Accordingly, no radiation mode beam is produced. Specifically, light is emitted from both end portions of a resonator in this light emitting element.

[0128] Oblique reflection mirrors 57 function to turn light beams output from both end portions of the resonator towards the modulators 60. In this case, the intensity of the output light is greater than the intensity of an output beam from a GCL.

[0129] If each reflection mirror 57 is formed of a concave mirror, a light beam of greater intensity can be guided to the modulator 60.

[0130] FIG. 14 shows an integrated device of a light emitting element and an external modulator according to a sixth embodiment of the invention.

[0131] This integrated device is not provided with an EA modulator. Modulation is effected by a method different from that in the preceding embodiments. This integrated device is mounted with a reflection mirror 56 situated on the heat sink side.

[0132] A radiation mode beam 103 output from a GCL 50 towards the substrate 1" is reflected by a reflection mirror 56 and guided towards the GCL 50. The reflection beam 103 interferes with a radiation mode beam 102 emitted to the outside from the GCL 50.

[0133] Modulation can be effected by varying the refractive index of an MQW layer 8' formed adjacent to the reflection mirror 56. Accordingly, the intensity of the output beam is increased by such interference as to intensity the radiation mode beams 102 and 103 and can be decreased by such interference as to weaken the radiation mode beams 102 and 103.

[0134] FIG. 15 shows an integrated device of a light emitting element and an external modulator according to a seventh embodiment of the invention.

[0135] In this integrated device, a DFB laser 50 and waveguide type EA modulators 62 are formed in the same plane. The DFB laser 50 has a second-order diffraction grating 15" at an end portion of a buried type waveguide. An advantage in this method resides in that a number of waveguide type EA modulators 62 can be provided in relation to one DFB laser.

[0136] FIG. 16 shows an integrated device of a light emitting element and an external modulator according to an eighth embodiment of the invention.

[0137] An optical communication system needs to have a light emitting element for transmitting an optical

signal, a light receiving element for receiving an optical element, and a light receiving element for monitoring the intensity of an optical signal output from the light emitting element.

5 [0138] If these elements are monolithically formed, the transmitter unit and receiver unit can be made to have the same structure and the manufacturing cost of the optical communication system can be reduced.

[0139] In this embodiment, in consideration of the above circumstances, there is provided an integrated device in which a surface-type light emitting element such as a GCL and a light receiving element such as a photodiode are monolithically formed.

10 [0140] A GCL 50 is formed on one major surface of an n-type InP substrate 1'.

[0141] Specifically, an n-type InP layer 1 and an InGaAsP active layer 2 are formed on said one major surface of the n-type InP substrate 1'. An opening is formed in a central portion of the InGaAsP active layer 2. The active layer 2 may be replaced with an active layer having an MQW (Multi-quantum well) structure capable of enhancing the device performance by virtue of quantum effect or a strained MQW structure.

15 [0142] An InGaAsP waveguide layer 3 is formed on the InGaAsP active layer 2 so as to completely fill the opening. The band gap of the InGaAsP waveguide layer 3 is greater than that of the InGaAsP active layer 2. A second-order grating 15 is formed on the upper surface of the InGaAsP waveguide layer 3.

20 [0143] A p-type InP layer 4 and a p-type InGaAsP ohmic-contact layer 5 are formed on the grating 15 of the InGaAsP waveguide layer 3.

[0144] The n-type InP layer 1, InGaAsP active layer 2, InGaAsP waveguide layer 3, p-type InP layer 4 and p-type InGaAsP ohmic-contact layer 5 are formed in stripes (e.g. ridges) extending in the longitudinal direction of the waveguide layer.

25 [0145] A p-side electrode 20 of the GCL 50 is formed on the p-type InGaAsP ohmic contact layer 5. An n-side electrode 21 of the GCL 50 is formed on the n-type InP substrate 1".

[0146] On the other hand, a PIN photodiode 70 is formed on the other major surface of the n-type InP substrate 1'.

30 [0147] Specifically, an n-type InP layer 26 and n'-type InGaAsP layer 27 are formed on said other major surface of the n-type InP substrate 1'. A p-type InGaAsP layer 28 is formed in the n'-type InGaAsP layer 27 in a position corresponding to the opening in the active layer

35 2. The p-type InGaAsP layer 28 can be formed by diffusing p-type impurities (e.g. Zn) in the n'-type InGaAsP layer 27. A p-side electrode 29 of the photodiode 70 is formed on the p-type InGaAsP layer 28. The n-side electrode 21 of the GCL 50 functions also as n-side electrode of the photodiode 70.

40 [0148] The integrated device having the above structure is mounted on a heat sink 32 by means of solder 31, with the photodiode 70 facing the heat sink 32.

[0149] The photodiode 70 can be used for monitoring, if a potential V_{LD} is applied to the electrode 20, a ground potential is applied to the electrode 21, a potential $-V_{PD}$ is applied to the electrode 29, a forward bias is applied to the GCL 50 and a reverse bias is applied to the photodiode 70. On the other hand, when the operation of the GCL 50 is stopped, the photodiode 70 can be used as light receiving element for receiving optical signals.

[0150] The photodiode 70 according to this embodiment can be used both for monitoring and receiving optical signals. Accordingly, the integrated device of this embodiment can be used both as an optical signal transmission device and an optical signal receiving device.

[0151] The refractive index of the opening portion (In-GaAsP) of the active layer 2 is lower than that of the surrounding portion thereof. Thus, the wavelength of a radiation mode beam 105 passing through the opening portion is shifted by $\lambda/4$ and the coupling coefficient of the GCL 50 is set at about 3. In this case, the radiation mode beam output from the GCL 50 has a highest intensity at the opening portion of the active layer 2.

Claims

1. An integrated device, comprising:

- a) a transparent semiconductor substrate (1"');
- b) at least one light emitting element (50) of a surface emission type, provided on a first major surface of said semiconductor substrate (1"'), said light emitting element (50) comprising a second-order grating (10) and radiating light radiated in a radiation mode vertically from said second-order grating (10); and
- c) at least one external modulator (60) formed on a second major surface of said semiconductor substrate (1"') such that it faces a light emitting plane of said light emitting element (50) so as to receive light radiated vertically from said second-order grating.

2. The integrated device according to claim 1,
characterized in that

at least one phase shift in said grating (10) or at least one region producing phase-shifting effect (16,16') to said grating (10) is provided for controlling the output intensity profile (or distribution) along said light emitting element (50).

3. The integrated device according to claim 1,
characterized in that

said light emitting element (50) has a waveguide, and both end portions of said waveguide is provided with anti-reflection coatings.

4. The integrated device according to claim 1,
characterized in that
said at least one external modulator (50) has a cylindrical mesa shape.

5. The integrated device according to claim 1,
characterized in that
said at least one external modulator (60) comprises an element having absorption properties variable due to application of an electric field.

6. The integrated device according to claim 1,
characterized in that
said at least one external modulator (60) functions also as a light receiving element for monitoring an optical signal output from said light emitting element (50).

7. The integrated device according to claim 6,
characterized in that
said light receiving element (50) is a PIN photodiode.

8. The integrated device according to claim 6,
characterized in that
said light emitting element (50) has an active layer (6) having a window portion which does not contain said active layer, and said light receiving element (50) being formed in a position facing to said window portion.

9. The integrated device according to claim 6,
characterized in that
the intensity of light is highest in a region wherein said light receiving element is situated.

10. The integrated device according to claim 6,
characterized in that
said light emitting element (50) and said light receiving element (60) are electrically connected to each other.

11. The integrated device according to claim 6,
characterized in that
said light emitting element (50) includes an active layer (2) having one of an MQW (Multi-Quantum Well) structure and a strained MQW structure.

12. The integrated device according to claim 1,
characterized by
a layer (25,6), for shutting out light output from said light emitting element (50) to a region other than a region where said at least one external modulator (60) is situated.

13. The integrated device according to claim 1,
characterized in that
the intensity of light in a region where said at least

- one external modulator (60) is situated is highest.
- 14. The integrated device according to claim 1,
*characterized by***
a lens (55) for decreasing an angle of broadening of the light output from said light emitting element (50), said lens being situated between said light emitting element (50) and said at least one external modulator (60).
- 15. The integrated device according to claim 1,
*characterized in that***
said light emitting element (50) and said at least one external modulator (60) are electrically isolated from each other.
- 16. The integrated device according to claim 1,
*characterized in that***
said light emitting element (50) emitting two radiation mode beams (102,103), one towards said external modulator (60) and the other towards an opposite direction, and said beam towards an opposite direction is reflected towards said modulator (60) by a reflective mirror (56) provided in the side opposite to said modulator (60).
- 17. The integrated device according to claim 1,
*characterized in that***
said light emitting element (50) emitting two radiation mode beams in opposite directions, one of said beams is reflected in the same direction as the other of said beams by a reflective mirror (56), and said reflective mirror (56) functions as a modulator (8') by varying the reflective phase of said reflective mirror.
- 18. The integrated device according to claim 1,
*characterized in that***
said light emitting element (50) includes an active layer (2) having one of an MQW (Multi-Quantum Well) structure and a strained MQW structure.
- 19. The integrated device according to claim 1,
*characterized in that***
said at least one external modulator (60) has an MQW (Multi-Quantum Well) structure.
- 20. The integrated device according to claim 1,
*characterized by***
external circuits connected to said modulator (60) said light emitting element (50), and further comprising of a heat sink (32) on which said integrated device is mounted.
- 21. The integrated device according to claim 1,
*characterized in that***
said second-order grating (10) is provided along at least one side of a waveguide structure of said light emitting element (50), and said modulator (60) comprises another waveguide structure of which direction is normal to said waveguide structure having second-order grating along there, provided on the same crystal plane as said light emitting element (50) is provided.
- Patentansprüche**
- 1. Integrierte Einrichtung, umfassend:**
- a) ein transparentes Halbleitersubstrat (1"');
 - b) wenigstens ein Lichtemissionselement (50) eines Oberflächenemissionstyps, das auf einer ersten Hauptoberfläche des Halbleitersubstrats (1") vorgesehen ist, wobei das Lichtemissionselement (50) ein Gitter (10) zweiter Ordnung umfasst und Licht abstrahlt, das in einem Strahlungsmodus vertikal von dem Gitter (10) zweiter Ordnung abgestrahlt wird; und
 - c) wenigstens einen externen Modulator (60), der auf einer zweiten Hauptoberfläche des Halbleitersubstrats (1") so gebildet ist, dass er auf eine Lichtemissionsebene des Lichtemissionselement (50) so gerichtet ist, dass es Licht, welches vertikal von dem Gitter zweiter Ordnung abgestrahlt wird, empfängt.
- 2. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, dass**
wenigstens eine Phasenverschiebung in dem Gitter (10) oder wenigstens ein Bereich, der einen Phasenverschiebeeffekt (16, 16') an dem Gitter (10) erzeugt, zum Steuern des Ausgangsintensitätsprofils (oder einer Verteilung) entlang des Lichtemissionselement (50) vorgesehen ist.
- 3. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß**
das Lichtemissionselement (50) einen Wellenleiter aufweist und beide Endabschnitte des Wellenleiters mit Antireflektionsbeschichtungen versehen ist.
- 4. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß**
wenigstens ein externer Modulator (50) eine zylindrische Mesa-Form aufweist.
- 5. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß**
wenigstens ein externer Modulator (60) ein Element mit Absorptionseigenschaften umfasst, die aufgrund einer Anwendung eines elektrischen Felds variabel sind.

6. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 wenigstens ein externer Modulator (60) auch als ein
 Lichtempfangselement zum Überwachen eines optischen Signals, das von dem Lichtemissionselement (50) ausgegeben wird, arbeitet.
7. Integrierte Einrichtung nach Anspruch 6,
dadurch gekennzeichnet, daß
 das Lichtempfangselement (50) eine PIN Photodiode ist.
8. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) eine aktive Schicht (6) mit einem Fensterabschnitt aufweist, der die aktive Schicht nicht enthält, und das Lichtempfangselement (50) an einer Position gebildet ist, die auf den Fensterabschnitt zugekehrt ist.
9. Integrierte Einrichtung nach Anspruch 6,
dadurch gekennzeichnet, daß
 die Lichtintensität in einem Bereich, in dem das Lichtempfangselement angeordnet ist, am höchsten ist.
10. Integrierte Einrichtung nach Anspruch 6,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) und das Lichtempfangselement (60) elektrisch miteinander verbunden sind.
11. Integrierte Einrichtung nach Anspruch 6,
dadurch gekennzeichnet, daß
 dass das Lichtemissionselement (50) eine aktive Schicht (2) umfasst, die eine MQW (Mehrfachquantentopf) Struktur oder eine gespannte MQW Struktur aufweist.
12. Integrierte Einrichtung nach Anspruch 1,
gekennzeichnet durch
 eine Schicht (25, 6), um Licht, das von dem Lichtemissionselement (50) ausgegeben wird, von einem anderen Bereich, als einem Bereich, an dem wenigstens ein externer Modulator (60) angeordnet ist, abzublocken.
13. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 die Lichtintensität in einem Bereich, in dem der wenigstens eine externe Modulator (60) angeordnet ist, am höchsten ist.
14. Integrierte Einrichtung nach Anspruch 1,
gekennzeichnet durch
 eine Linse (55) zum Verkleinern eines Verbreitungswinkels des Lichts, das von dem Lichtemissionselement (50) ausgegeben wird, wobei die Linse
- zwischen dem Lichtemissionselement (50) und dem wenigstens einem externen Modulator (60) angeordnet ist.
- 5 15. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) und der wenigstens eine externe Modulator (60) voneinander elektrisch isoliert sind.
16. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) zwei Strahlungsmodus-Strahlen (102, 103) emittiert, einen in Richtung auf den externen Modulator (60) hin und den anderen in eine entgegengesetzte Richtung hin, und der Strahl in Richtung auf eine entgegengesetzte Richtung hin durch einen Reflektionsspiegel (56), der in der gegenüberliegenden Seite zu dem Modulator (60) vorgesehen ist, auf den Modulator (60) hin reflektiert wird.
17. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) zwei Strahlungsmodus-Strahlen in entgegengesetzte Richtungen emittiert, wobei einer der Strahlen in die gleiche Richtung wie der andere der Strahlen durch einen Reflektionsspiegel (56) reflektiert wird, und der Reflektionsspiegel (56) als ein Modulator (8') durch Ändern der relativen Phase des Reflektionsspiegels arbeitet.
18. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Lichtemissionselement (50) eine aktive Schicht (2) mit einem MQW (Mehrfachquantentopf) Struktur und einer gespannten MQW Struktur aufweist.
- 35 19. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 der wenigstens eine externe Modulator (60) eine MQW (Mehrfachquantentopf) Struktur aufweist.
- 40 20. Integrierte Einrichtung nach Anspruch 1,
gekennzeichnet durch
 externe Schaltungen, die mit dem Modulator (60) und dem Lichtemissionselement (50) verbunden sind, und ferner umfassend eine Wärmesenke (32), in der die integrierte Einrichtung angebracht ist.
- 50 21. Integrierte Einrichtung nach Anspruch 1,
dadurch gekennzeichnet, daß
 das Gitter (10) zweiter Ordnung entlang wenigstens einer Seite einer Wellenleiterstruktur des Lichtemissionselement (50) vorgesehen ist und der Modulator (60) eine andere Wellenleiterstruktur umfasst, dessen Richtung normal zu der Wellenleiter-

struktur mit dem Gitter zweiter Ordnung dort entlang ist, vorgesehen auf der gleichen Kristallebene, wo das Lichtemissionselement (50) vorgesehen ist.

Revendications

1. Dispositif intégré, comprenant :

- a) un substrat semi-conducteur transparent (1"');
- b) au moins un élément émetteur de lumière (50) du type à émission de surface, disposé sur une première grande face dudit substrat semi-conducteur (1"), ledit élément émetteur de lumière (50) comprenant un réseau (10) du second ordre et rayonnant de la lumière émise en mode rayonnement verticalement depuis ledit réseau (10) du second ordre ; et
- c) au moins un modulateur externe (60) formé sur une seconde grande face dudit substrat semi-conducteur (1") de façon à faire face à un plan d'émission de lumière dudit élément émetteur de lumière (50) de façon à recevoir de la lumière émise verticalement par ledit réseau du second ordre.

2. Dispositif intégré selon la revendication 1, caractérisé en ce que :

il est prévu au moins un déphasage dans ledit réseau (10) ou au moins une région (16, 16') produisant un effet de déphasage pour ledit réseau (10), pour commander le profil (ou la répartition) d'intensité de sortie le long dudit élément émetteur de lumière (50).

3. Dispositif intégré selon la revendication 1, caractérisé en ce que :

ledit élément émetteur de lumière (50) comporte un guide d'onde, et en ce que les deux parties d'extrémité du guide d'onde sont pourvues de revêtements antiréfléchissants.

4. Dispositif intégré selon la revendication 1, caractérisé en ce que :

ledit au moins un modulateur externe (60) a une forme de mesa cylindrique.

5. Dispositif intégré selon la revendication 1, caractérisé en ce que :

ledit au moins un modulateur externe (60) comprend un élément ayant des propriétés d'absorption variables en raison de l'application d'un champ électrique.

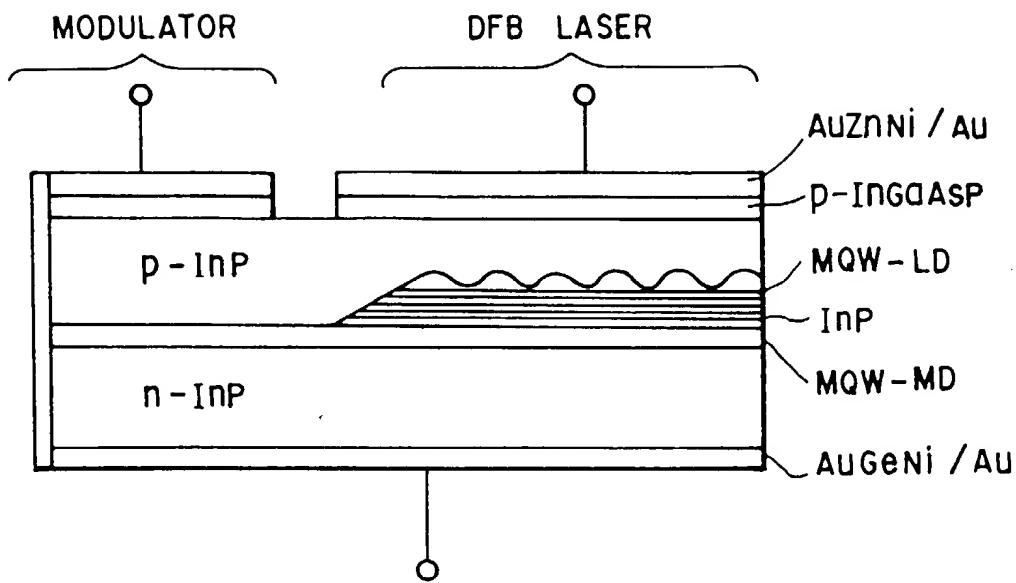
6. Dispositif intégré selon la revendication 1, caractérisé en ce que :

ledit au moins un modulateur externe (60)

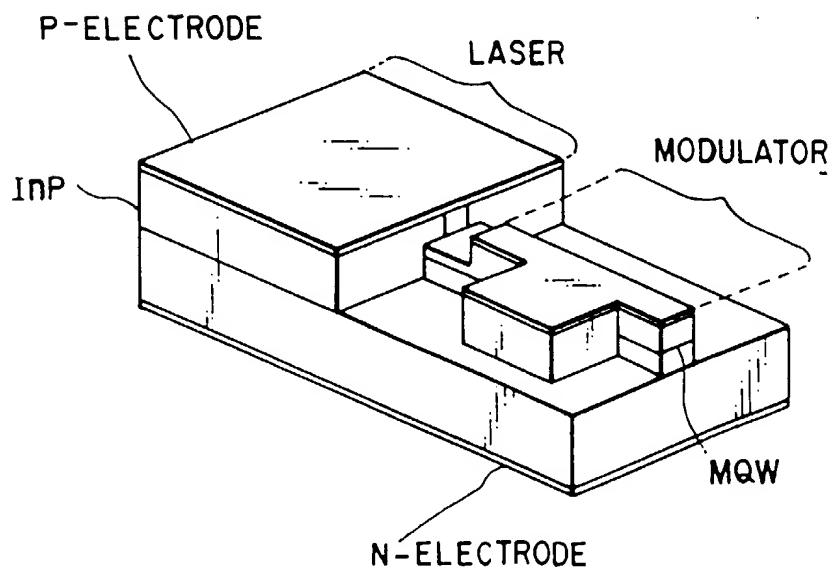
fonctionne aussi comme un élément récepteur de lumière pour surveiller un signal optique sorti dudit élément émetteur de lumière (50).

- 5 7. Dispositif intégré selon la revendication 6, caractérisé en ce que :
ledit élément récepteur de lumière (50) est une photodiode PIN.
- 10 8. Dispositif intégré selon la revendication 6, caractérisé en ce que :
ledit élément émetteur de lumière (50) comporte une couche active (6) possédant une partie formant fenêtre qui ne contient pas ladite couche active, et en ce que ledit élément récepteur de lumière (50) est formé dans une position faisant face à ladite partie formant fenêtre.
- 15 9. Dispositif intégré selon la revendication 6, caractérisé en ce que :
l'intensité de lumière est la plus élevée dans une région dans laquelle est situé ledit élément récepteur de lumière.
- 20 10. Dispositif intégré selon la revendication 6, caractérisé en ce que :
ledit élément émetteur de lumière (50) et ledit élément récepteur de lumière (60) sont connectés électriquement l'un à l'autre.
- 25 11. Dispositif intégré selon la revendication 6, caractérisé en ce que :
ledit élément émetteur de lumière (50) comprend une couche active (2) ayant l'une d'une structure de MQW (puits quantique multiple) et d'une structure de MQW contrainte.
- 30 12. Dispositif intégré selon la revendication 1, caractérisé par :
une couche (25, 6), destinée à éteindre la lumière sortie dudit élément émetteur de lumière (50) vers une région autre qu'une région où est situé ledit au moins un modulateur externe (60).
- 35 13. Dispositif intégré selon la revendication 1, caractérisé en ce que :
l'intensité de lumière est la plus élevée dans une région où est situé ledit au moins un modulateur externe (60).
- 40 14. Dispositif intégré selon la revendication 1, caractérisé par :
une lentille (55) destinée à diminuer l'angle d'étalement de la lumière sortie dudit élément émetteur de lumière (50), ladite lentille étant située entre ledit élément émetteur de lumière (50) et ledit au moins un modulateur externe (60).
- 45 50 55

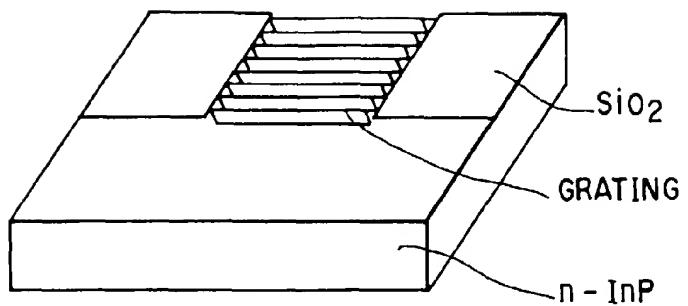
- 15.** Dispositif intégré selon la revendication 1,
caractérisé en ce que :
ledit élément émetteur de lumière (50) et ledit
au moins un modulateur externe (60) sont isolés
électriquement l'un de l'autre. 5
- 16.** Dispositif intégré selon la revendication 1,
caractérisé en ce que :
ledit élément émetteur de lumière (50) émet
deux faisceaux (102, 103) en mode rayonnement,
l'un en direction dudit modulateur externe (60) et
l'autre en sens contraire, et en ce que ledit faisceau
dirigé en sens contraire est réfléchi en direction du-
dit modulateur (60) par un miroir réfléchissant (56)
disposé du côté opposé audit modulateur (60). 10
- 17.** Dispositif intégré selon la revendication 1,
caractérisé en ce que :
ledit élément émetteur de lumière (50) émet
deux faisceaux en mode rayonnement en sens con-
traire, en ce que l'un desdits faisceaux est réfléchi
dans la même direction que l'autre desdits fais-
ceaux par un miroir réfléchissant (56), et en ce que
ledit miroir réfléchissant (56) fonctionne comme un
modulateur (8') en faisant varier la phase de ré-20
flexion dudit miroir réfléchissant. 25
- 18.** Dispositif intégré selon la revendication 1,
caractérisé en ce que :
ledit élément émetteur de lumière (50) com-30
prend une couche active (2) ayant l'une d'une struc-
ture de MQW (puits quantique multiple) et d'une
structure de MQW contrainte.
- 19.** Dispositif intégré selon la revendication 1, 35
caractérisé en ce que :
ledit au moins un modulateur externe (60) a
une structure de MQW (puits quantique multiple).
- 20.** Dispositif intégré selon la revendication 1, 40
caractérisé par :
des circuits externes connectés audit modu-
lateur (60) audit élément émetteur de lumière (50),
et comprenant en outre un dissipateur (32) de cha-
leur sur lequel est monté ledit dispositif intégré. 45
- 21.** Dispositif intégré selon la revendication 1,
caractérisé en ce que :
ledit réseau (10) du second ordre est disposé
le long d'au moins un côté d'une structure de guide
d'onde dudit élément émetteur de lumière (50), et
en ce que ledit modulateur (60) comprend une autre
structure de guide d'onde dont la direction est per-
pendiculaire à ladite structure de guide d'onde le
long duquel se trouve le réseau du second ordre,
disposée sur le même plan de cristal que celui où
est disposé ledit élément émetteur de lumière (50). 50
- 55



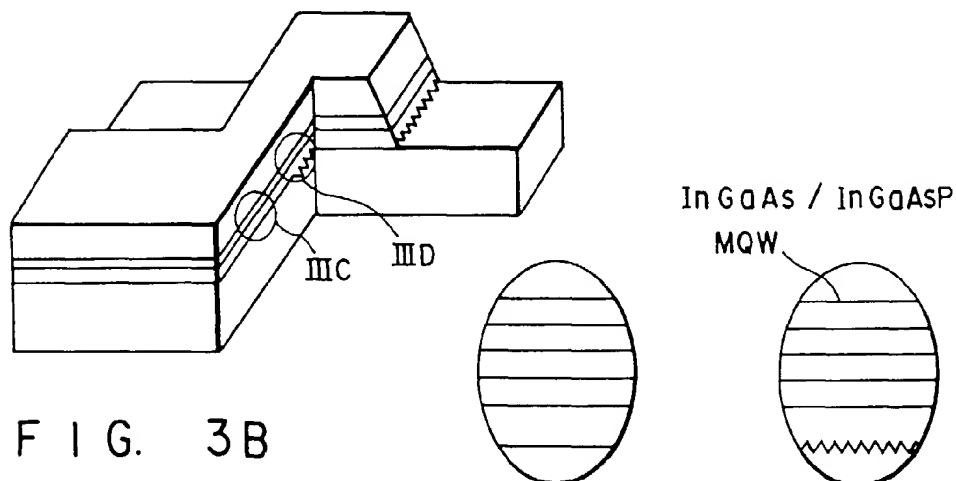
F I G. 1



F I G. 2

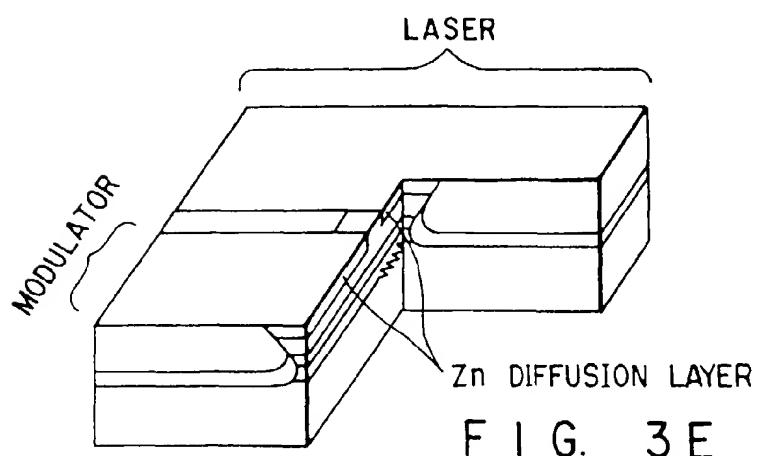


F I G. 3 A



F I G. 3 B

F I G. 3 C F I G. 3 D



F I G. 3 E

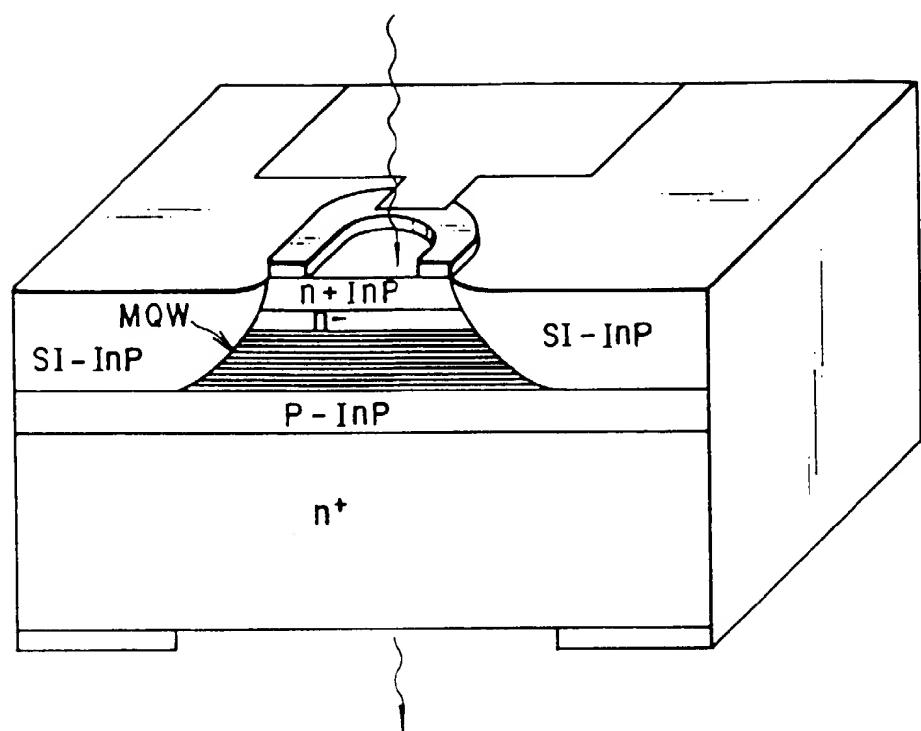


FIG. 4

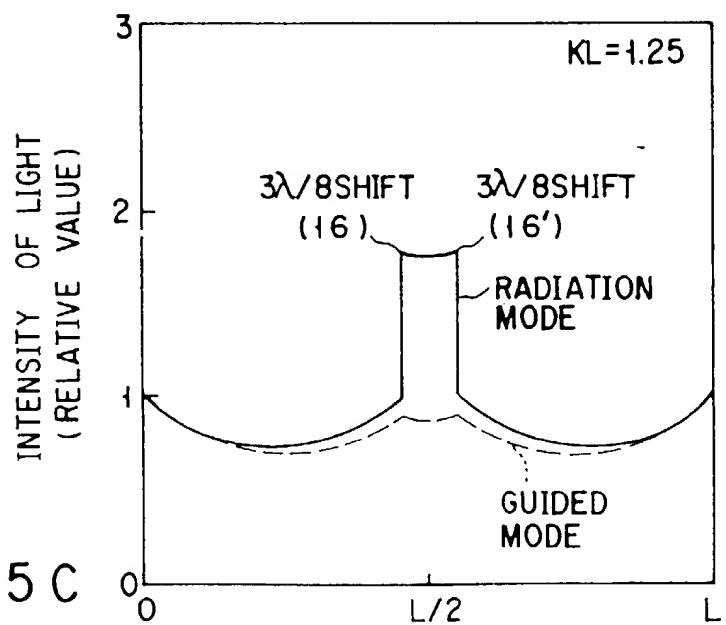
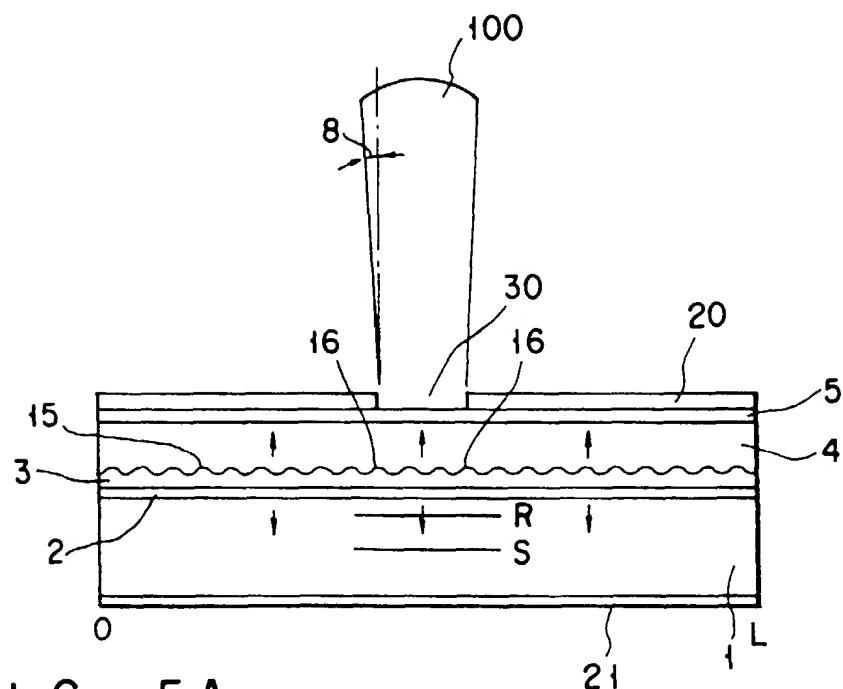
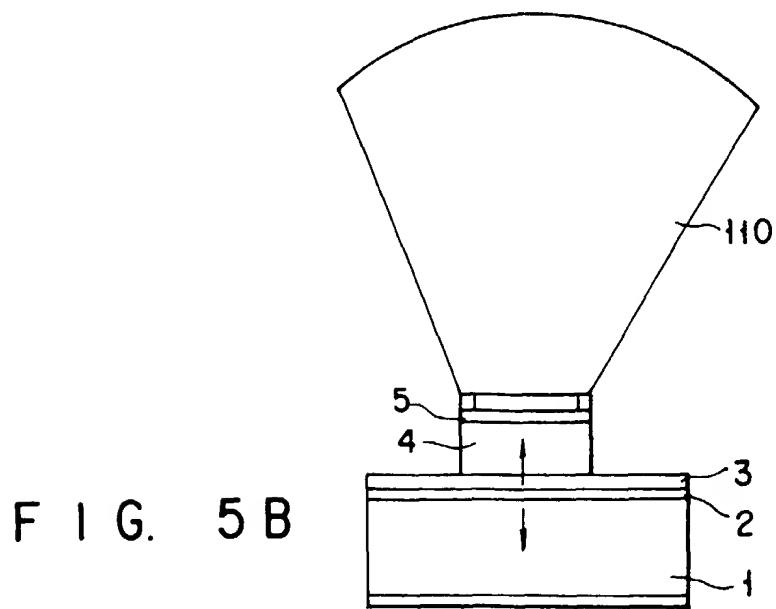


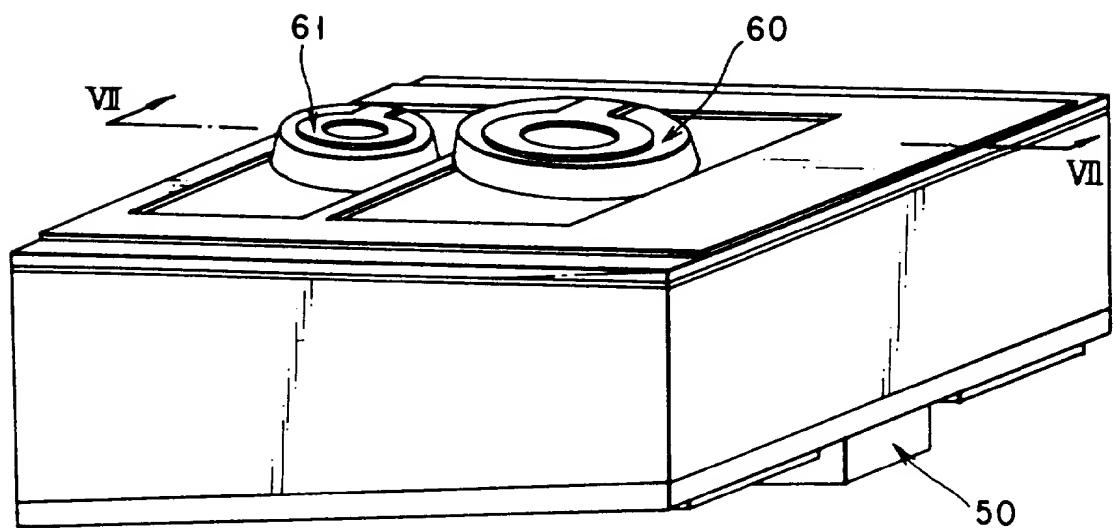
FIG. 5 C



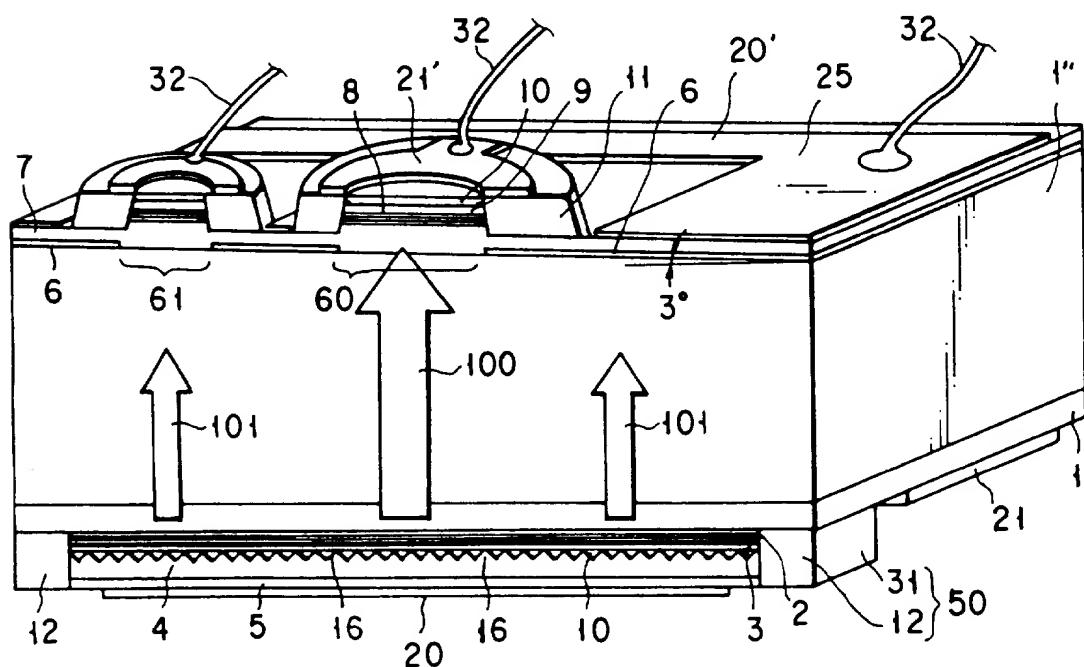
F I G. 5 A



F I G. 5 B



F I G. 6



F I G. 7

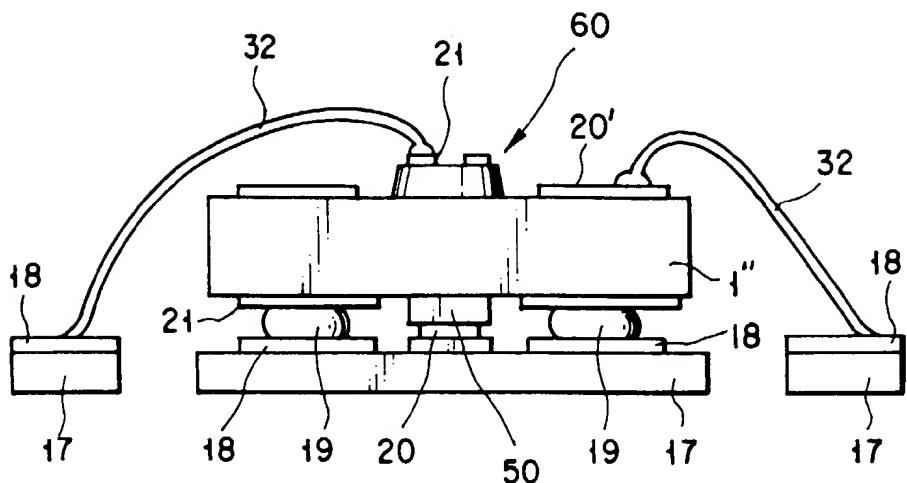


FIG. 8

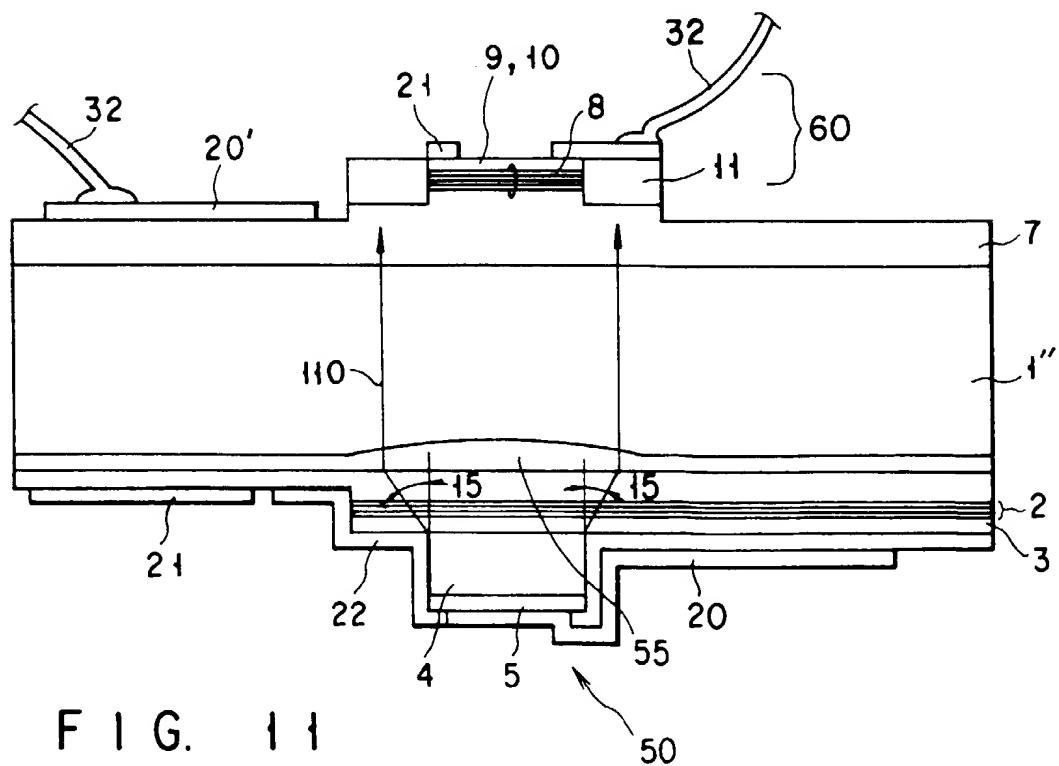


FIG. 11

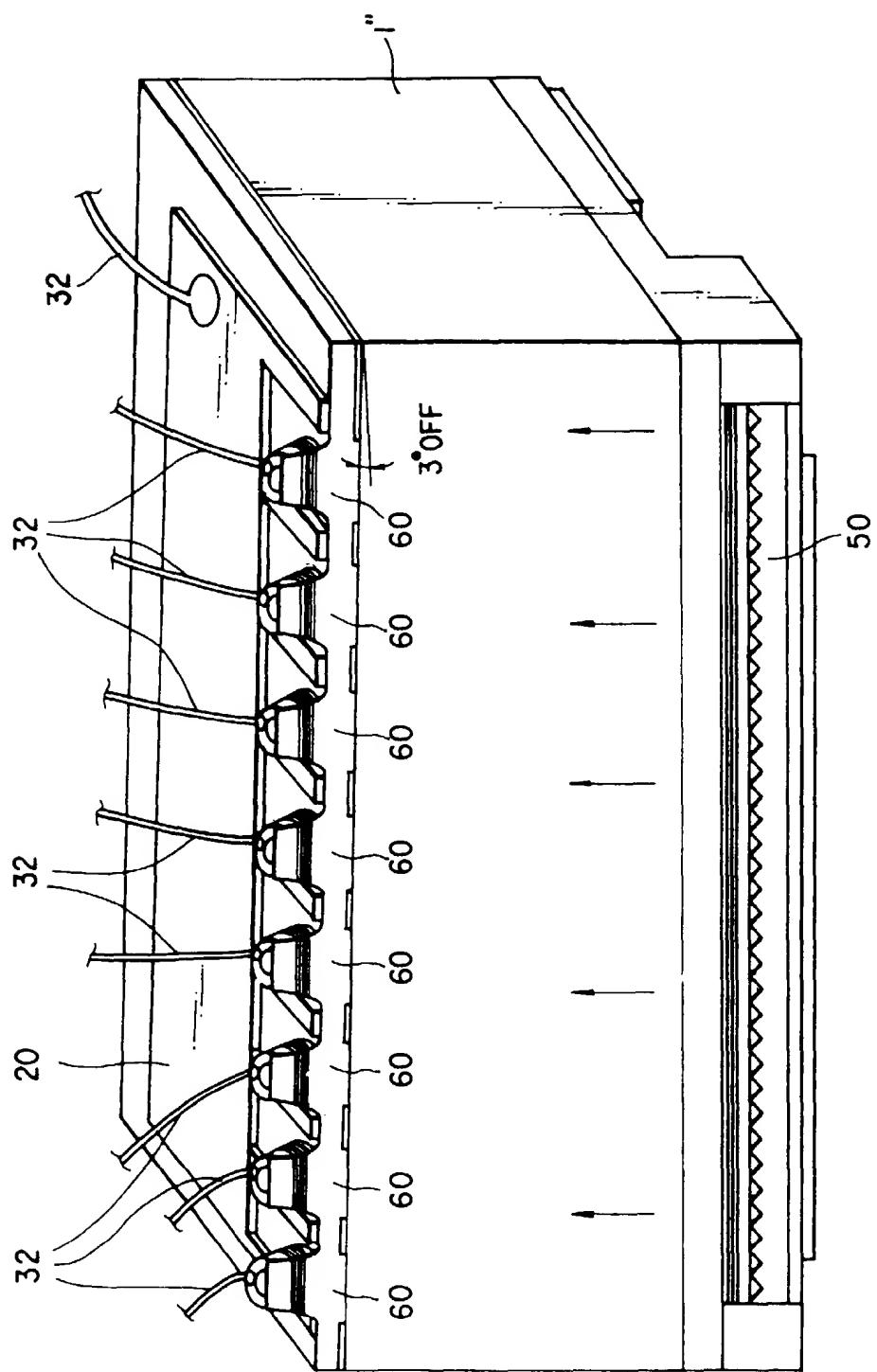
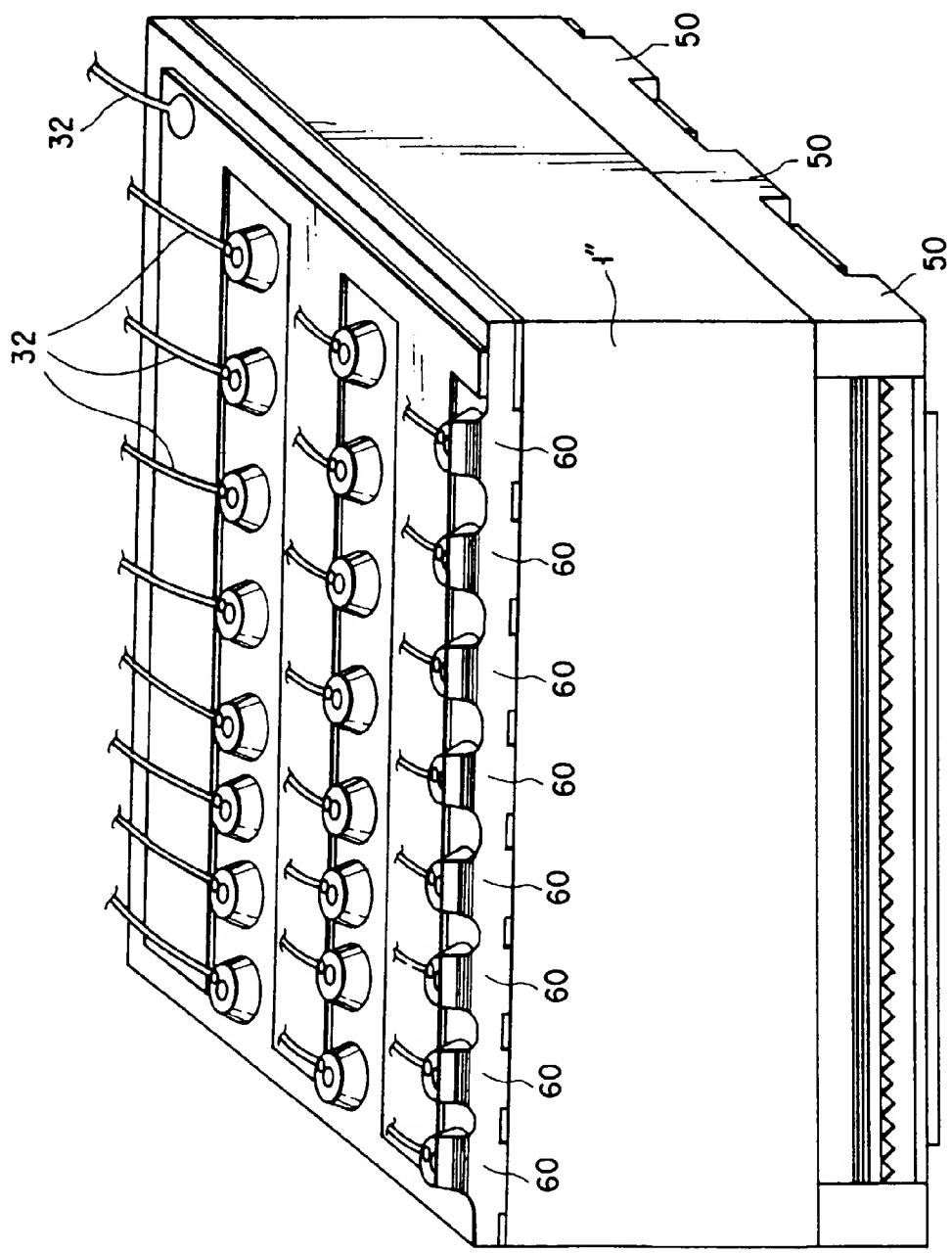
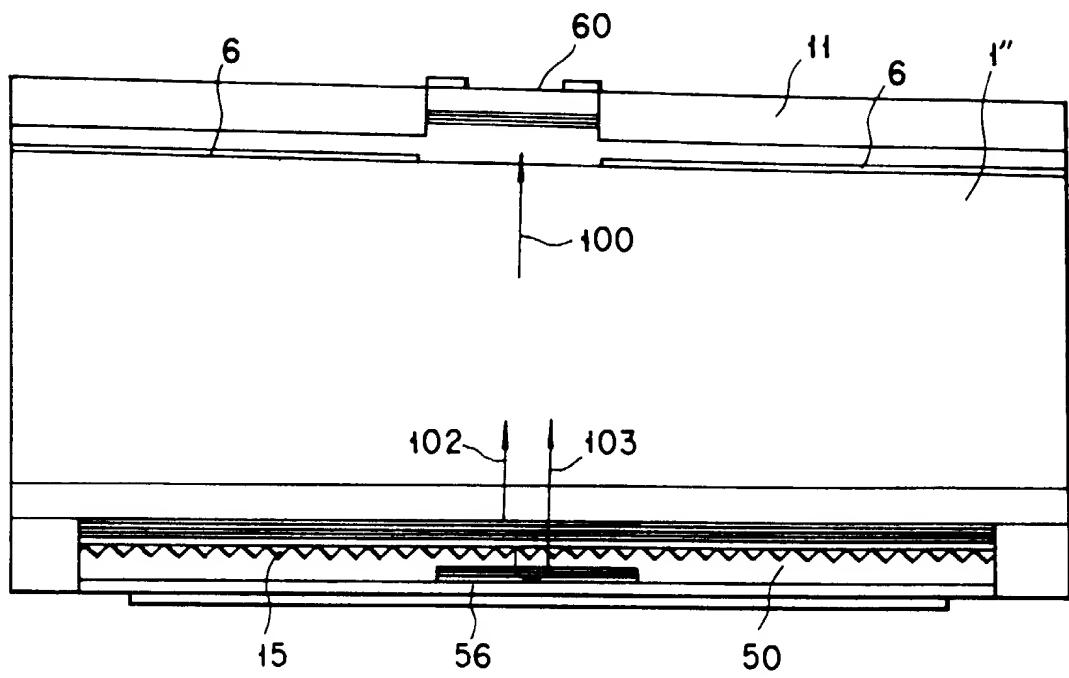


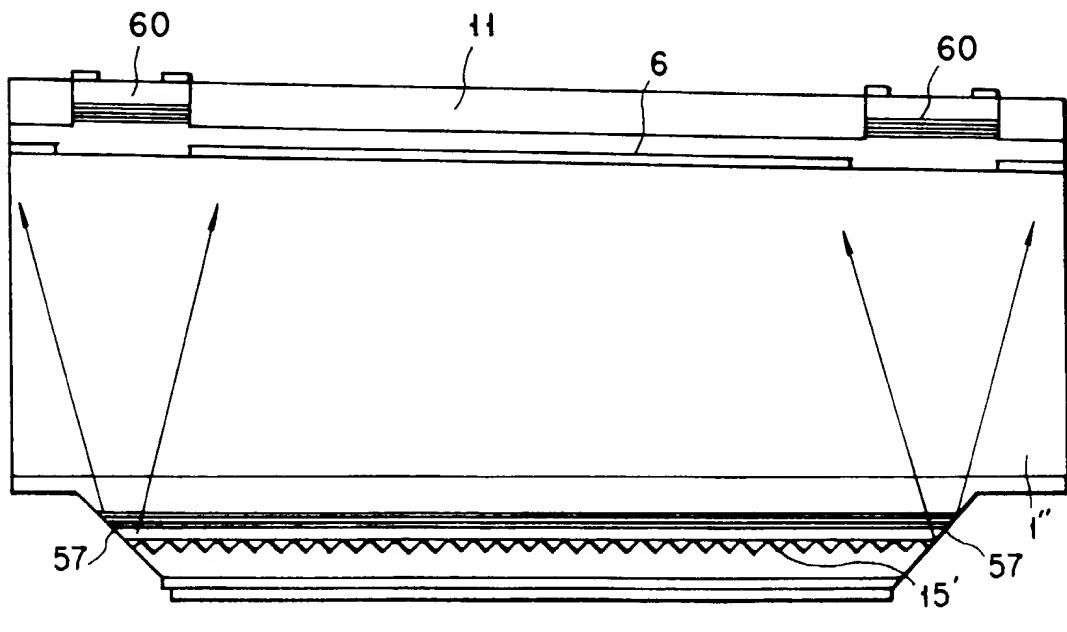
FIG. 9



F I G. 10



F I G. 12



F I G. 13 51

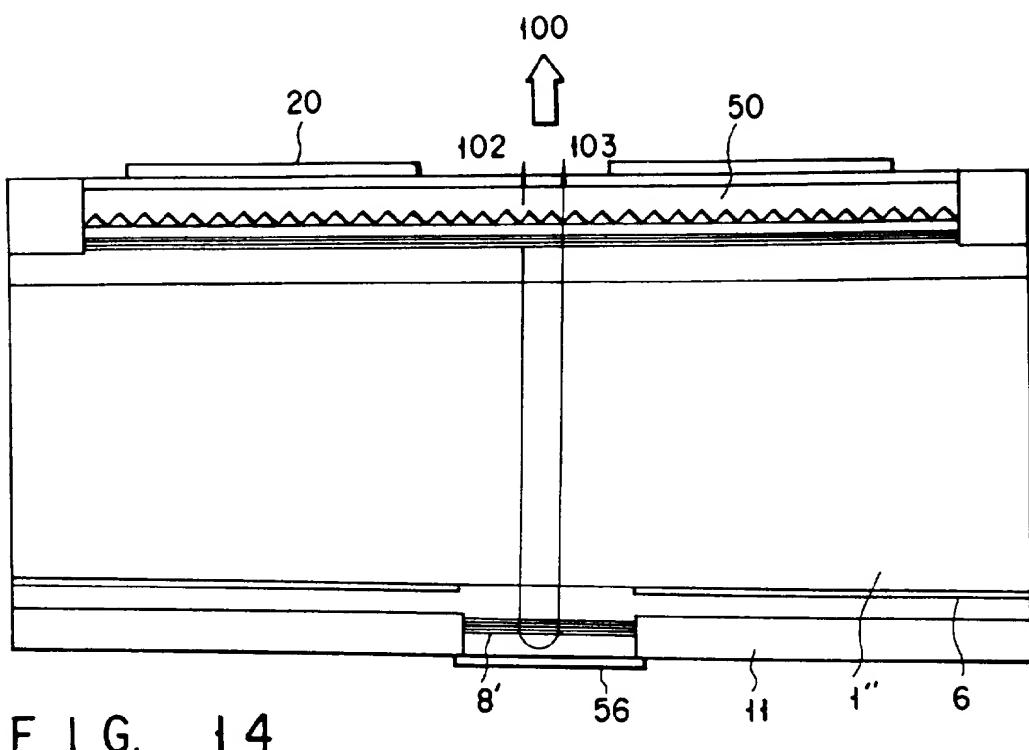


FIG. 14

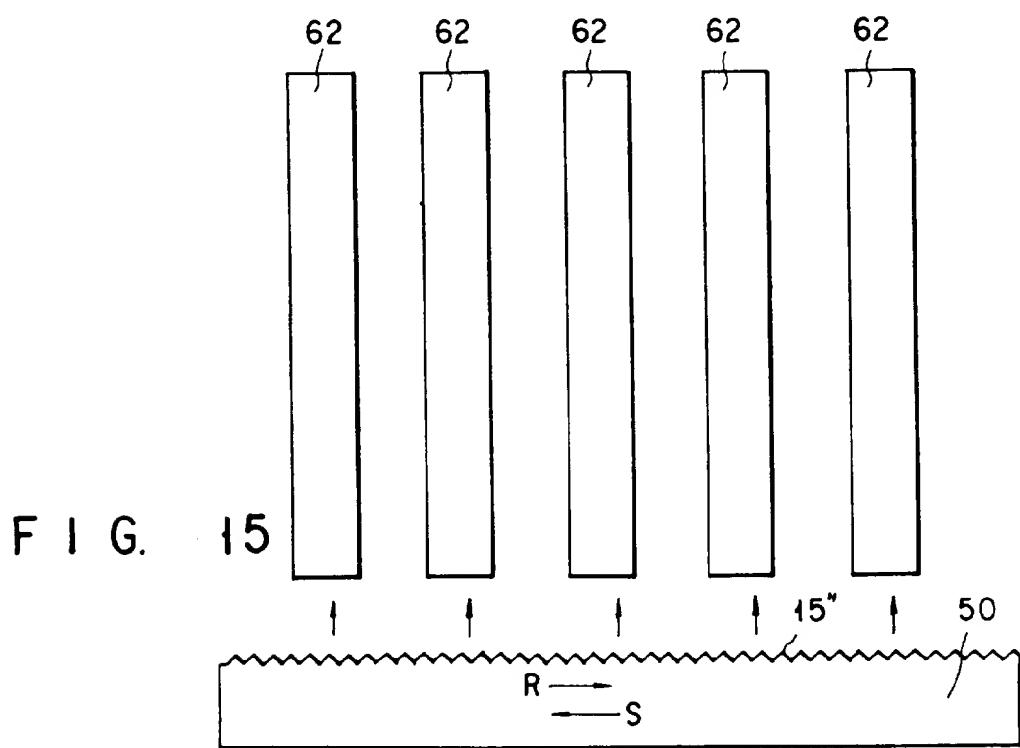
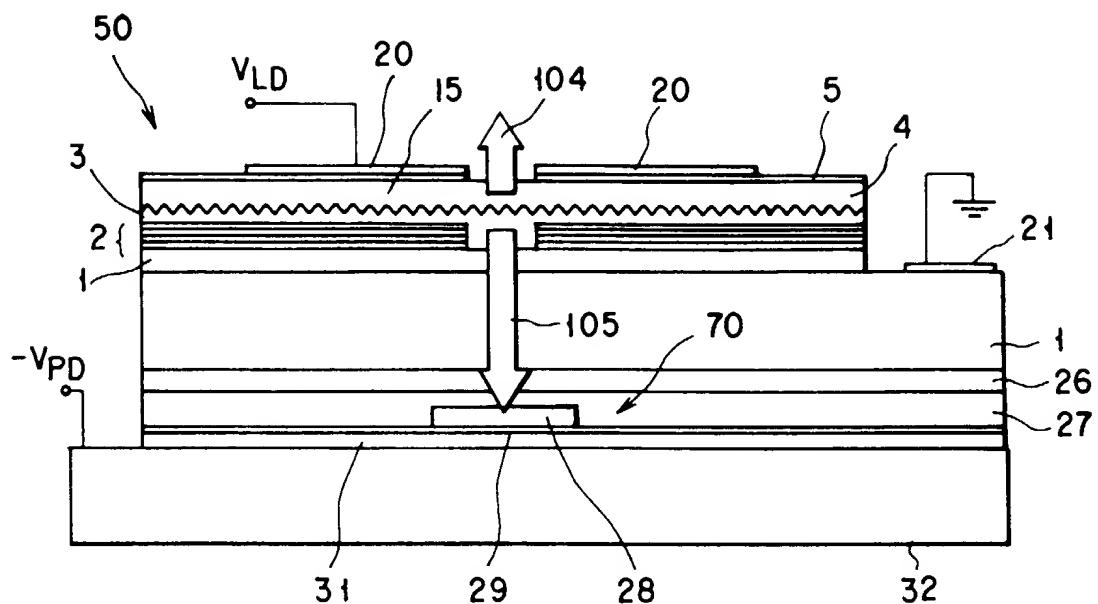
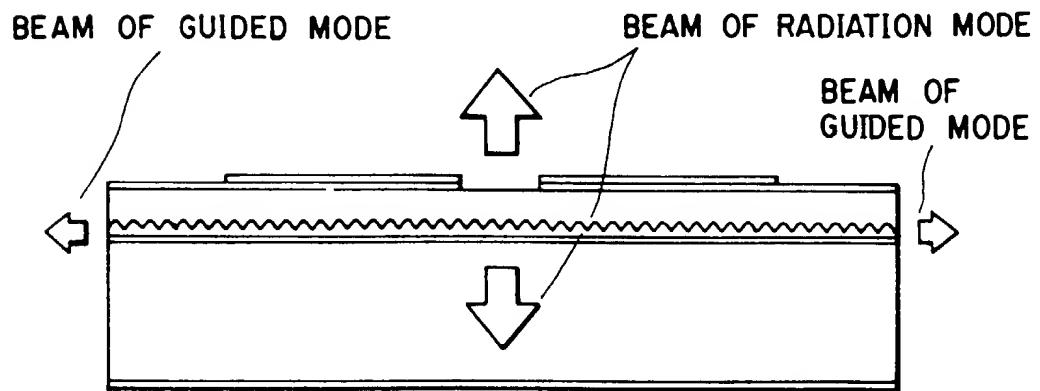


FIG. 15



F I G. 16



F I G. 17